Re: Tamar Elsawy et al.
Vapor Drying System and Method
SCP-5020 (Continuation)
Express Mail:EL816894144US
Stallman & Pollock LLP
Sheet 1 of 12

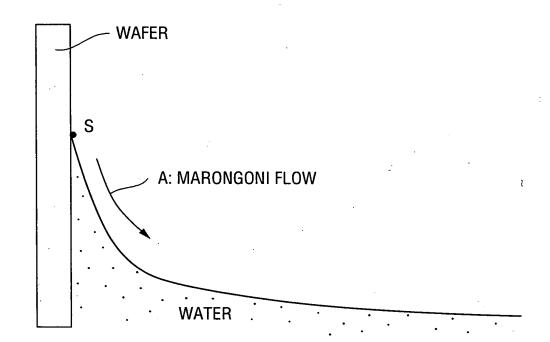
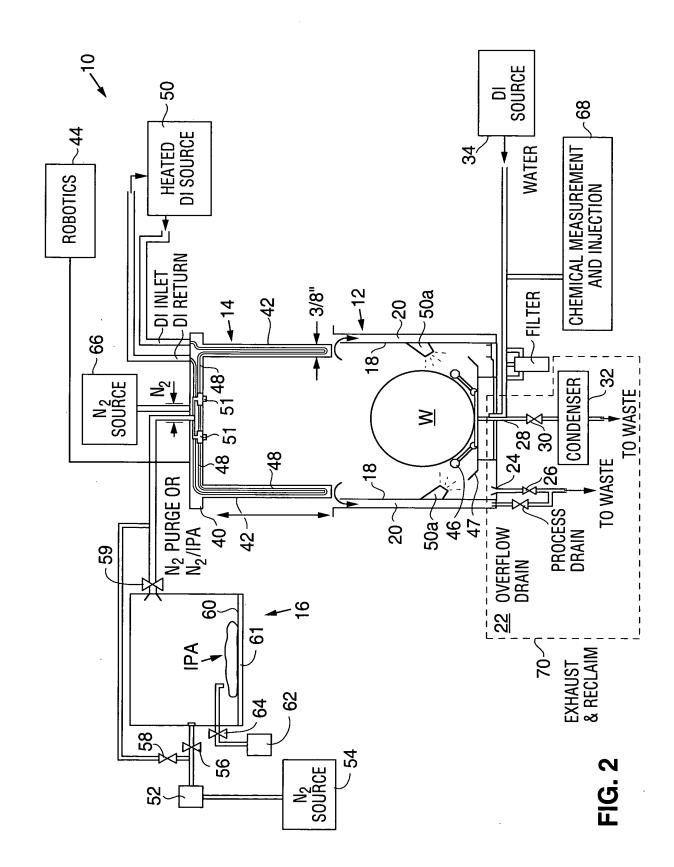
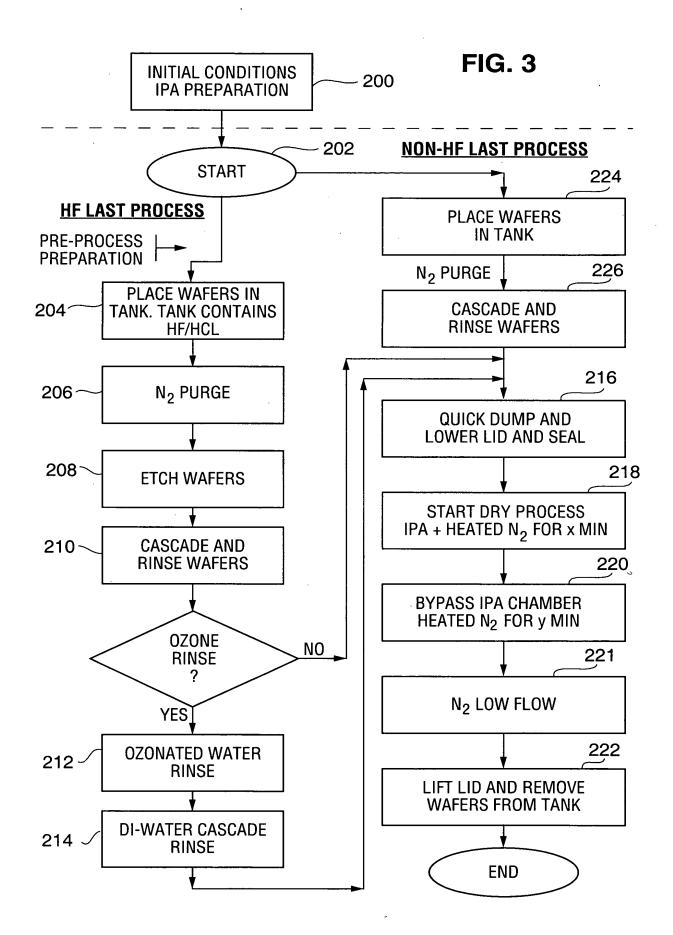


FIG. 1 (PRIOR ART)

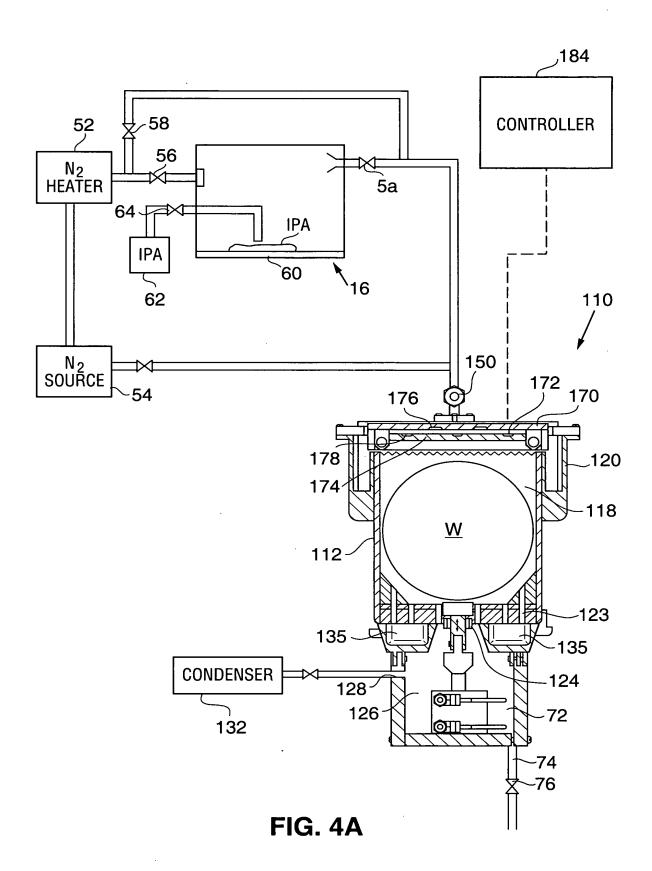
Re: Tamar Lisawy et al.
Vapor Drying System and Melliod
SCP-5020 (Continuation)
Express Mail:EL816894144US
Stallman & Pollock LLP
Sheet 2 of 12



Ke: I amar Elsawy et al.
Vapor Bryling System and Method
SCP-5020 (Continuation)
Express Mail:EL816894144US
Stallman & Pollock LLP
Sheet 3 of 12



Re: Tamar Elsawy et al. Vapor Drying System and Method SCP-5020 (Continuation) Express Mail:EL816894144US Stallman & Pollock LLP Sheet 4 of 12



Re: Tamar Elsawy et al. Vapor Drying System and Method SCP-5020 (Continuation) Express Mail:EL816894144US Stallman & Pollock LLP Sheet 5 of 12

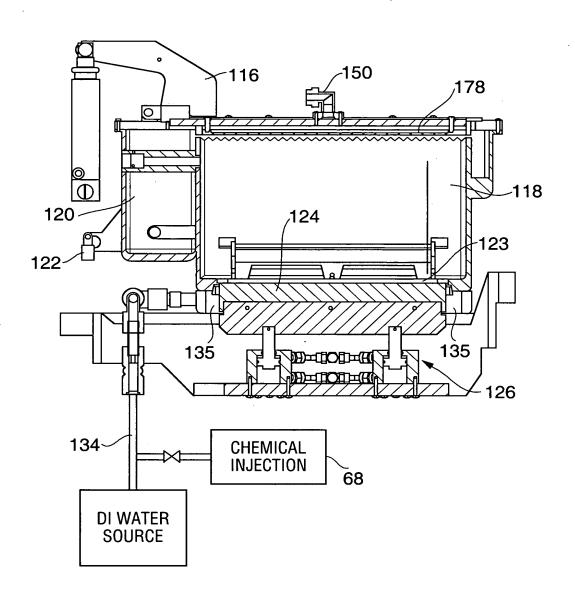


FIG. 4B

Re: Tamar Elsawy et al. Vapor Drying System and Method SCP-5020 (Continuation) Express Mail:EL816894144US Stallman & Pollock LLP Sheet 6 of 12

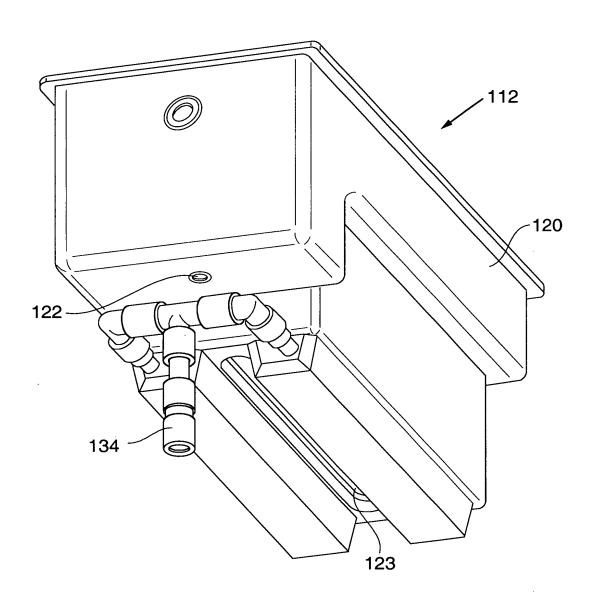


FIG. 4C

Re: Tamar Elsawy et al.

Vapor Drying System and Method

CP-5020 (Continuation)

kpress Mail:EL816894144US

Stallman & Pollock LLP

Sheet 7 of 12

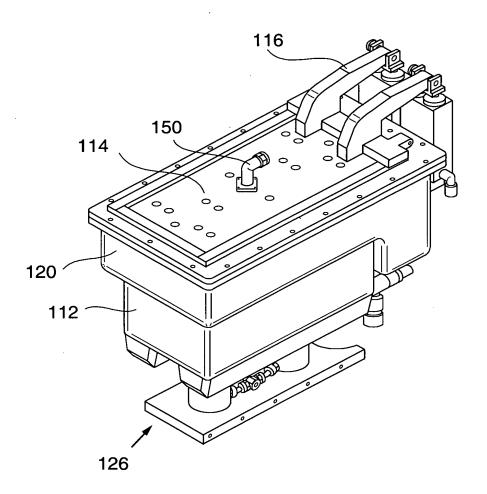
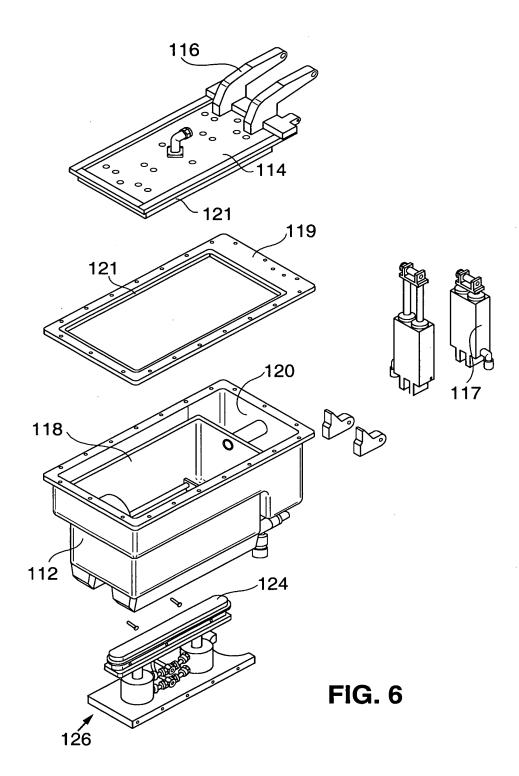


FIG. 5

Re: Tamar Elsawy et al.
Vapor Drying System and Method
SCP-5020 (Continuation)
Express Mail:EL816894144US
Stallman & Pollock LLP
Sheet 8 of 12



Re: Tamar Elsawy et al.
Vapor Drying System and Method
CP-5020 (Continuation)
xpress Mail:EL816894144US
Stallman & Pollock LLP
Sheet 9 of 12

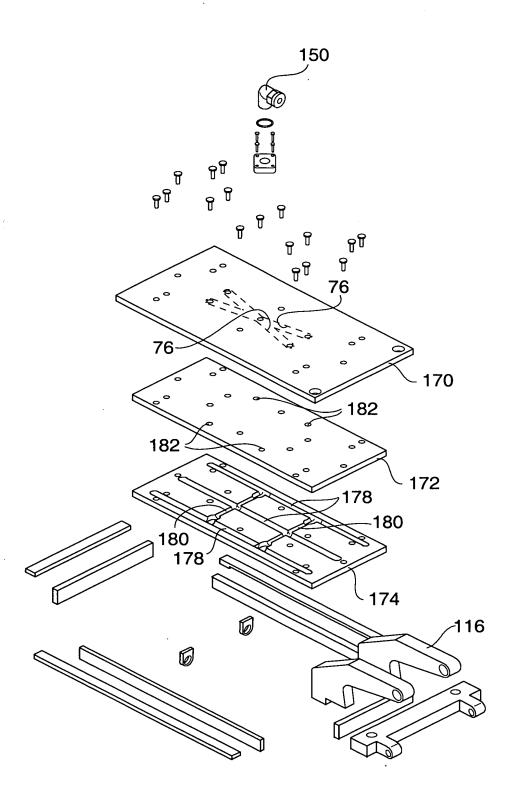
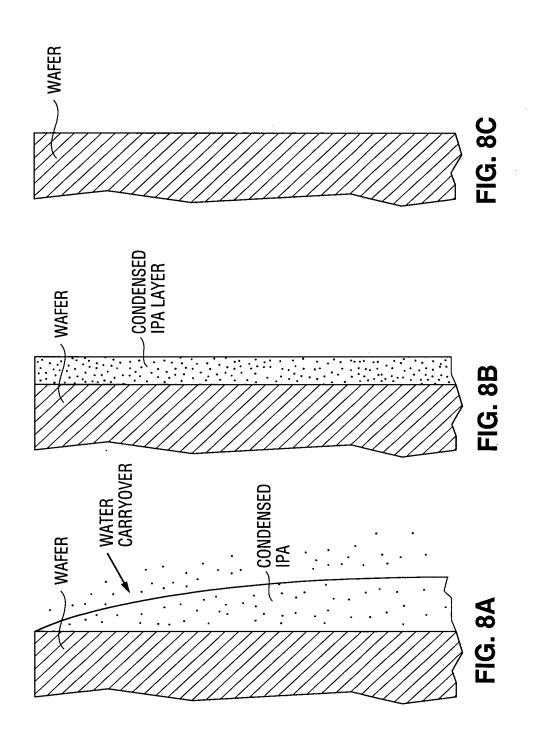
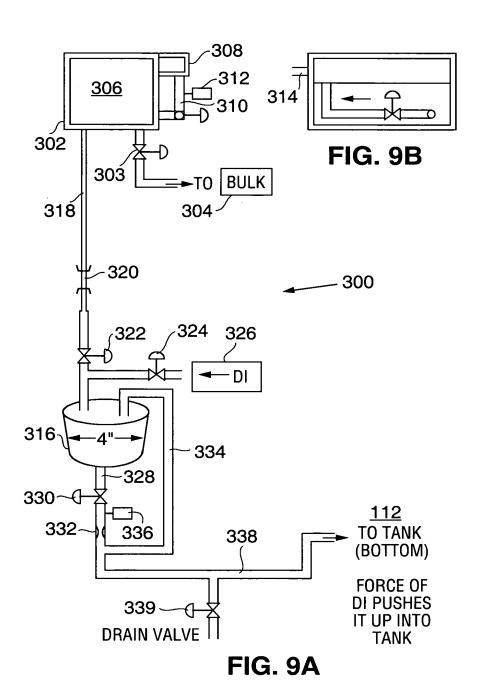


FIG. 7

Re: I amar Elsawy et al.
Vapor Bryling System and Method
SCP-5020 (Continuation)
Express Mail:EL816894144US
Stallman & Pollock LLP
Sheet 10 of 12



Re: Tamar Elsawy et al. Vapor Drying System and Method SCP-5020 (Continuation) Express Mail:EL816894144US Stallman & Pollock LLP Sheet 11 of 12



Re: Tamar Elsawy et al.
Vapor Drying System and Method
CP-5020 (Continuation)
.press Mail:EL816894144US
Stallman & Pollock LLP
Sheet 12 of 12

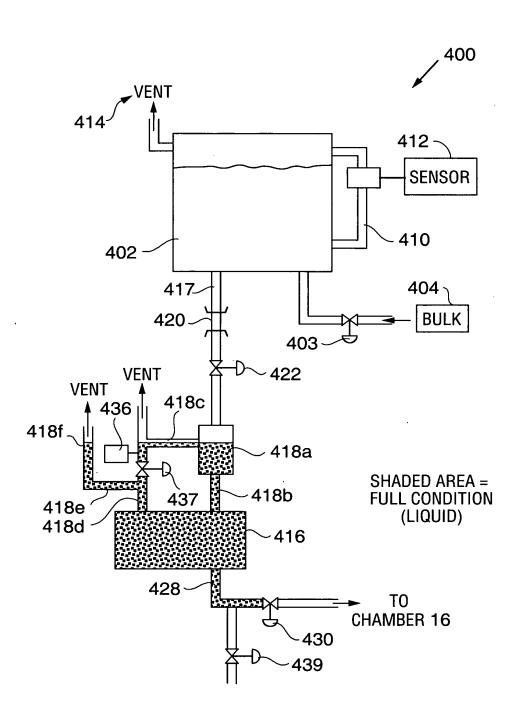


FIG. 10